

Fig. 2

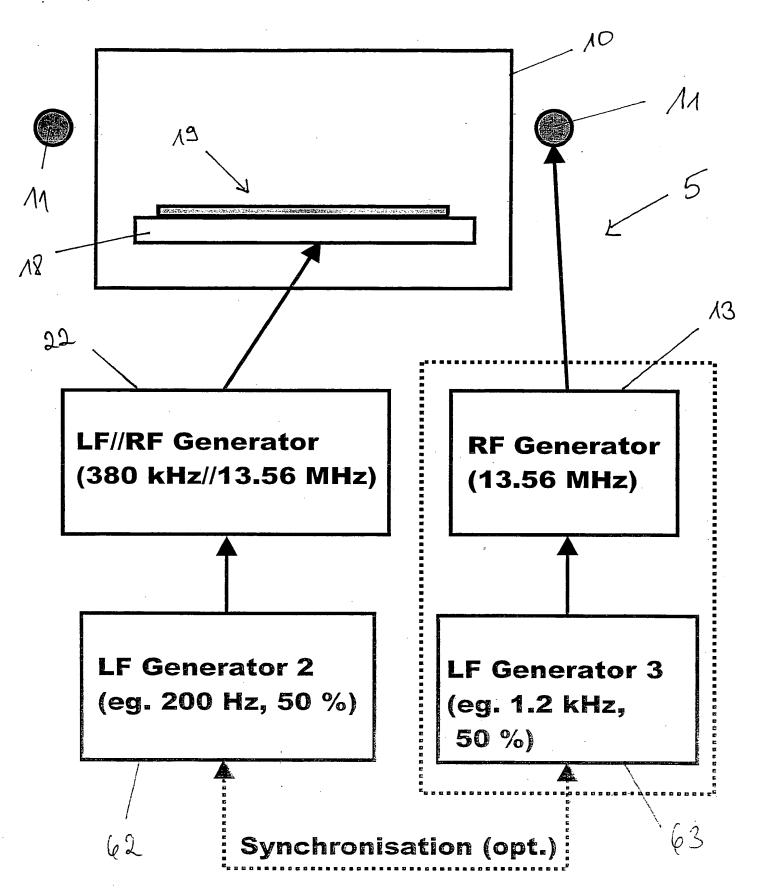
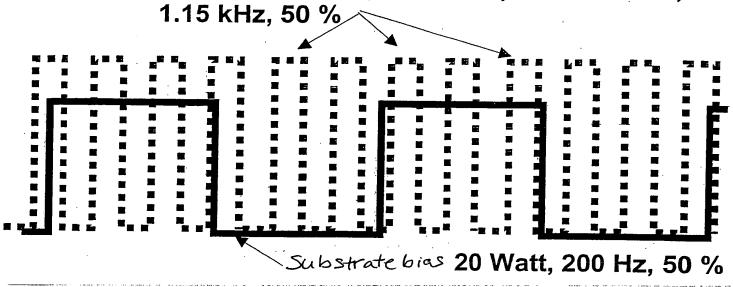
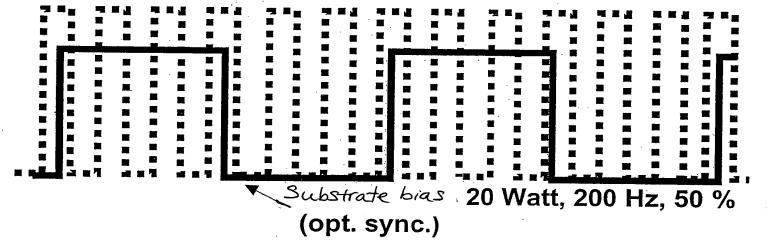


Fig. 3

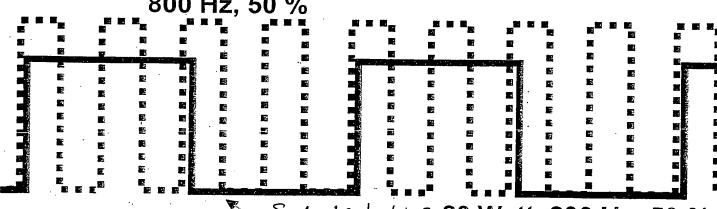
Plasna power, (ICP-Power): e.g. 3 kWatt,



Plasma power (ICP-Power): e.g. 3 kWatt, 1.20 kHz, 50 %



Plasmanpower (ICP-Power): e.g. 3 kWatt, 800 Hz, 50 %



Substrate bias 20 Watt, 200 Hz, 50 % (opt. sync.)

Fig. 5

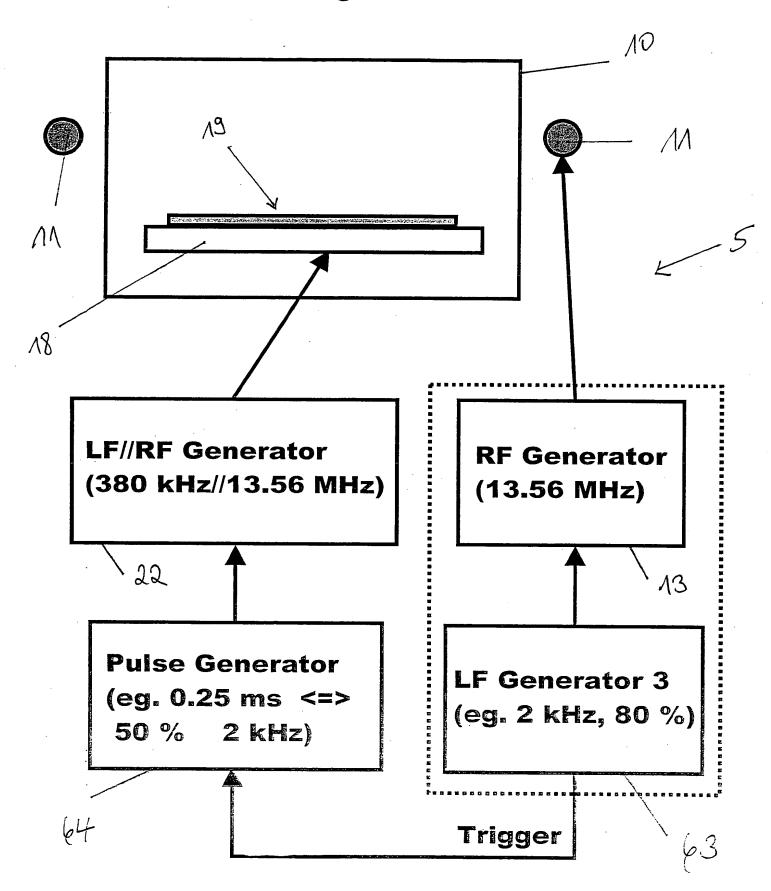
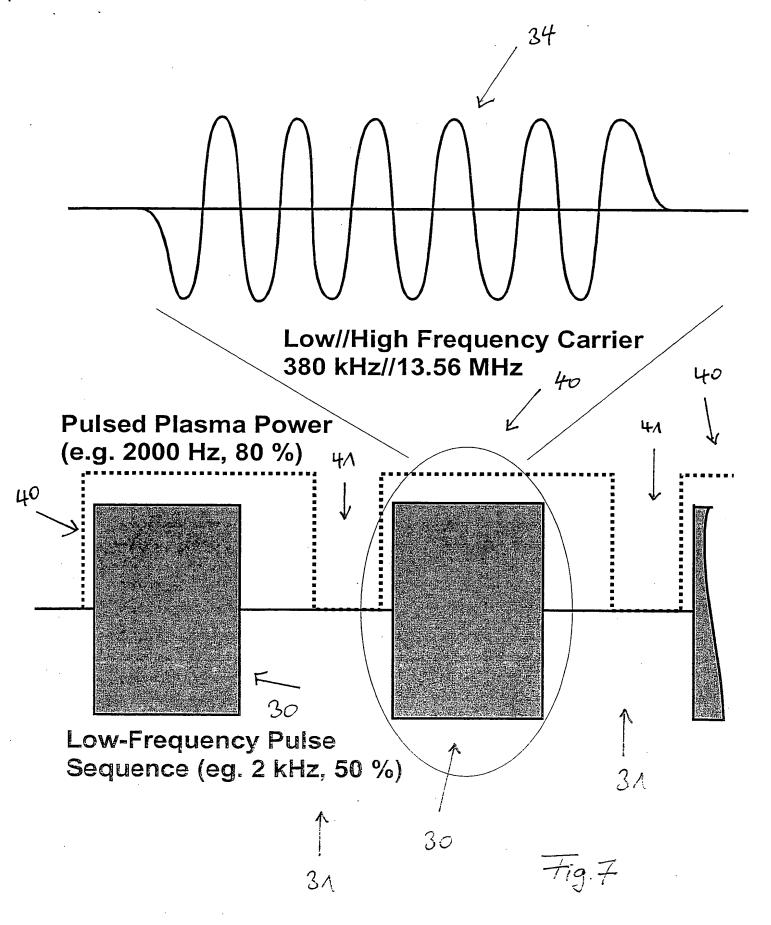
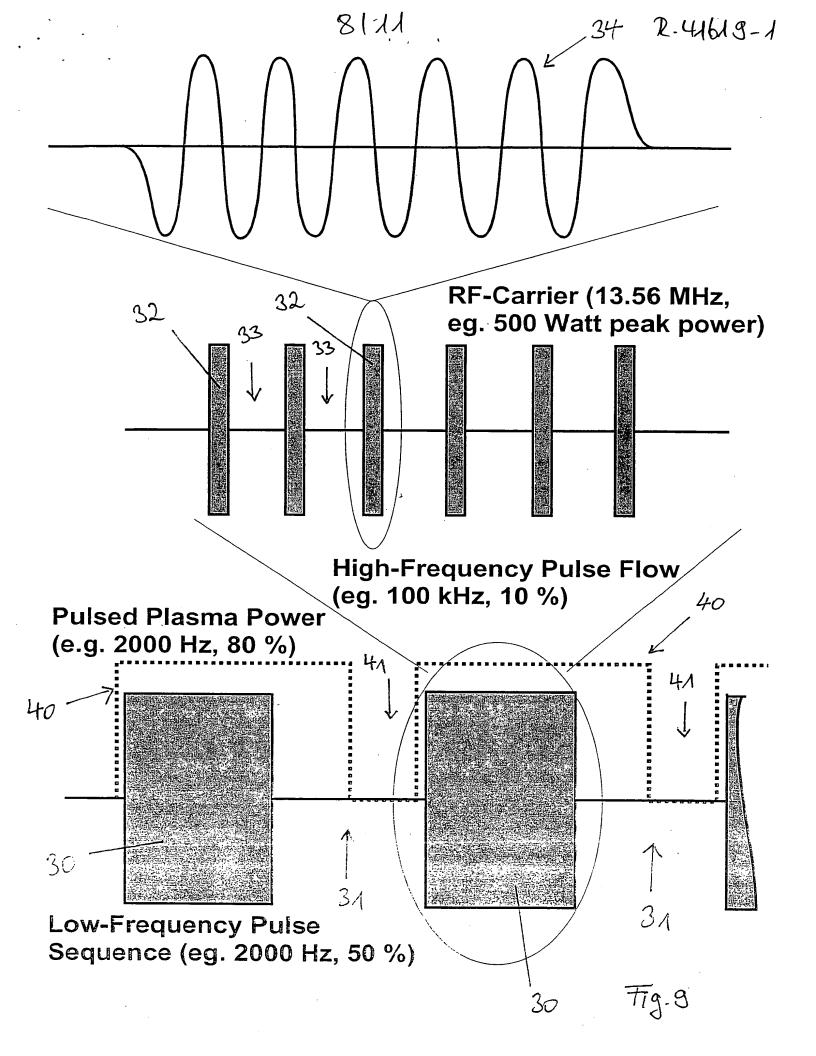
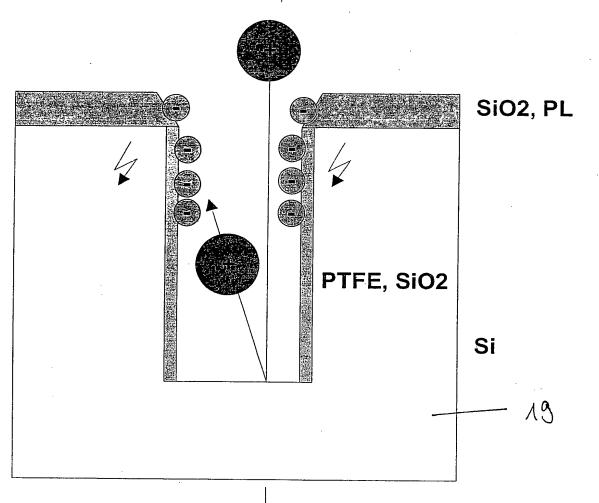
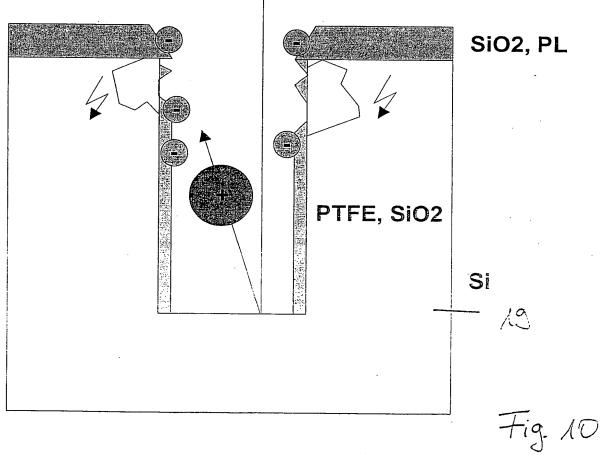


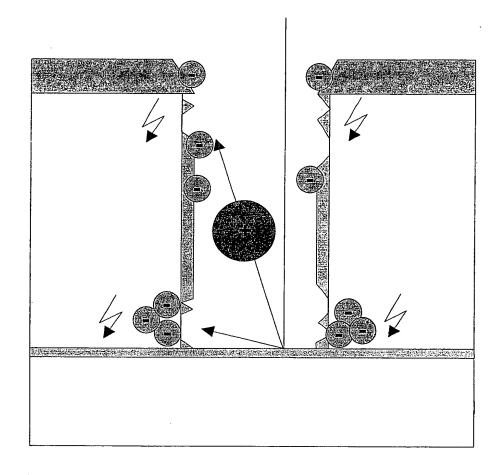
Fig. 6











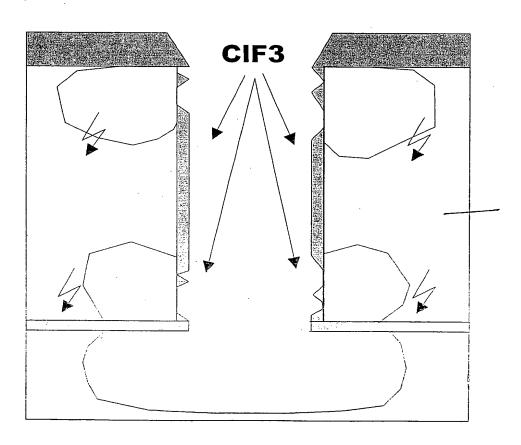
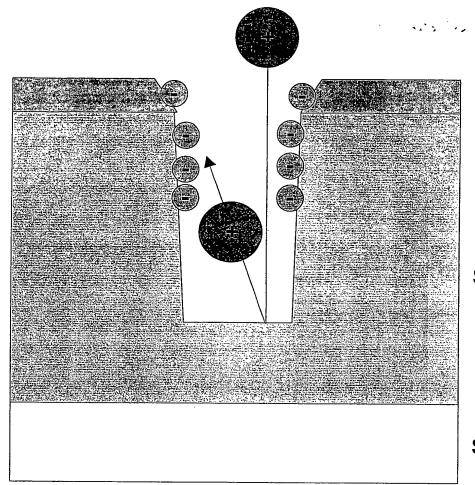
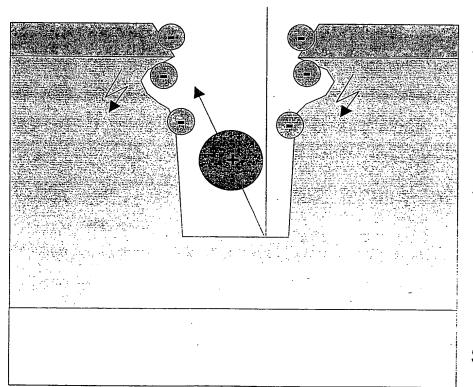


Fig. M



SiO2

Si



SiO2

Si

Fig. 12